IN THE SPECIFICATION:

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The specification as amended below with replacement paragraphs shows added text with <u>underlining</u> and deleted text with <u>strikethrough</u>.

Please Amend the paragraph beginning at page 20, line 19 and ending on page 21, line 1, as follows:

The thickness of the coating layer is preferably 20 to 200 μ m, more preferably 30 to–18 μ m180 μ m. The brilliancy is reduced to cause that the brightness is undesirably reduced when the coating layer thickness is less than 20 μ m. The degree of brilliancy is increased to reduce light scattering property to cause that the linear light source is undesirably shown through when the coating layer thickness exceeds 200 μ m.

Please Amend the paragraph beginning at page 24, line 10 and ending on page 25, line 3, as follows:

A light diffusion plate having the base material layer (A) and the coating resin layers (b) laminated on the both side of the base material layer (A) was prepared by using a laminated sheet extruder (manufactured by Plabor Co., Ltd.) having a feed block die, a polishing roller, and two extruders (each manufactured by Pla Giken Co., Ltd.; product type: PG) each having a screw diameter of 60 mm and 25 mm. An extruder temperature was set to 260°C; a die temperature was set to 250°C; a polishing roller temperature was set to 100°C; and a polishing roller nip line pressure was set to 20 kgf/cm. A thickness of the coating layer resin (B) was controlled in accordance with a ratio of an amount of the extruded base material layer resin (A), and the coextrusion was so performed as to achieve the thickness of about 30 μ30 μm on each of the surfaces. A thickness of the light diffusion plate was controlled to be 2 mm by adjusting the extruded amount of the base material layer resin (A) and a gap between the polishing rollers.